

Document 'AO in IDS

NOTICE OF REASONS FOR REJECTION

Mailing No. 175910

Mailing Date: May 27, 2003

Patent Application Number:	Patent Application No. 2000-401228
Draft Date:	May 21, 2003
Patent Office Examiner	Masaya Ito 3011 2M00
Applicant's Attorney	Yukio Takanasi
Applied Law	Section 29, subsection 2

This application is to be rejected for the following reasons. Please submit any argument as Remarks within 60 days from the mailing date of this notice.

REASONS

Inventions directed to the following claims in this application could easily have been made, prior to the filing of the application, by a person with ordinary skill in the art to which the invention pertains, on the basis of an invention or inventions described in the following cited references distributed in Japan or foreign countries, and is not patentable under the Patent Law Section 29, subsection 2 ("§29(2)").

REMARKS

Claims 1-23

Ref. No.1

Note: Ref. 1 applies a surface process for correcting aberration and a mask error onto at least one surface of a transmission circuit in the mask that uses the transmission circuit instead of a thin film pellicle (see paragraphs nos. [0032], [0086] - [0120]).

Ref. No. 1 is directed to the surface process for the transmission circuit applied to a aspheric surface process (see FIG. 12), using grinding (see FIG. 13) and fluorine doped fused quartz or calcium fluoride (see paragraph no. 0029).

Description of "reduce correction" in claim 22 of the present application is indefinite and deems to be a typographical error.

LIST OF CITED REFERENCES

1. Japanese Patent Application No. 2000-49802 (Patent Application Publication No.

10-21-2003 01:36pm From-MORGAN&FINNEGAN

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T-646 P.003/003 F-358

2001-117213)

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Examiner A. Mathews	U.S. Patent & Trademark Office	703-746-4365	703-308-1706
FROM: John A. Harroun		DATE: October 21, 2003	
IF YOU DO NOT RECEIVE ALL PAGES, PLEASE CALL: (202) 857-8038		CLIENT/MATTER: 1232-4807	
CONFIRM:		PAGES (INCLUDING COVER): 3	

COMMENTS:


RE: U.S. Serial No. 10/033,081
Patent Application of Tsuneo KANDA
For: MASK AND PROJECTION EXPOSURE APPARATUS
Atty. Docket No. 1232-4807
Filed: December 27, 2001

Examiner Mathews:

Further to our conversation yesterday (10/20/03), please find attached a copy of the English translation of the Notice of Reasons for Rejection submitted with the IDS filed on September 15, 2003 in the above identified application.

If you require any further information in this case, please do not hesitate to contact me directly on 202-857-8038. Thank you for your prompt attention to this matter.

Best regards,


John Harroun

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